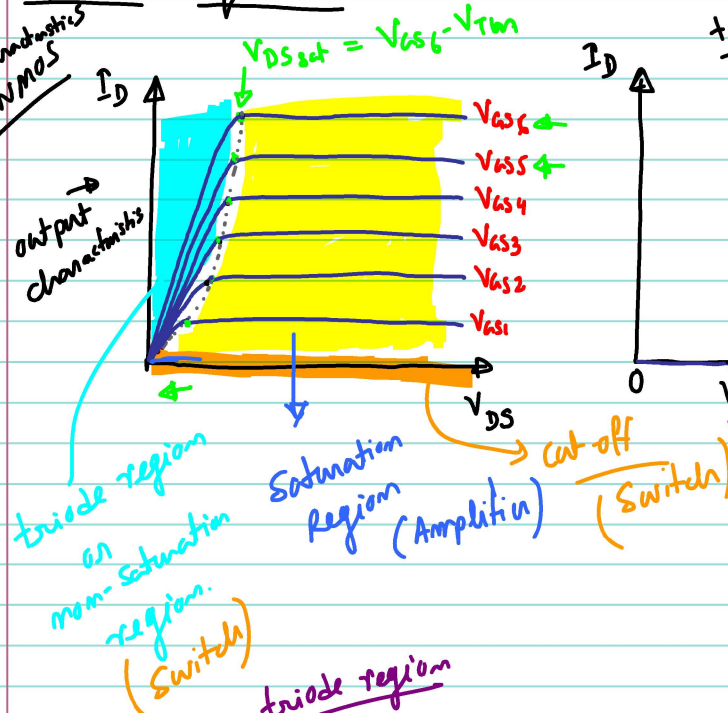
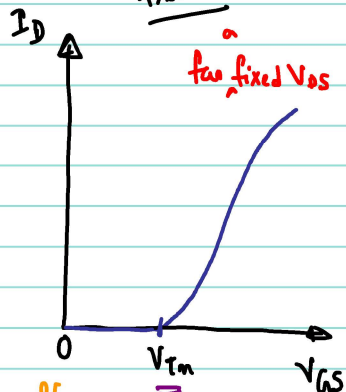


MOSFET Equations:

Characteristics
NMOS



transfer characteristics
a fixed VDS



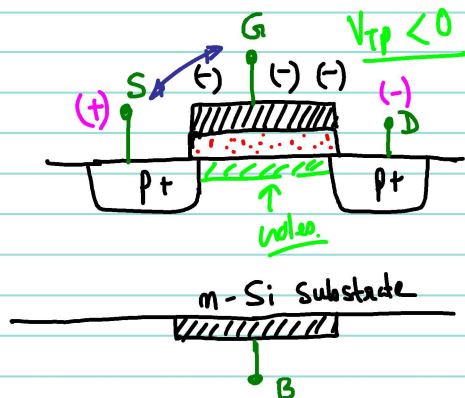
Equations: $I_D = k_m [2 (V_{GS} - V_{TH}) V_{DS} - V_{DS}^2] ; V_{GS} > V_{TH}$

saturation region $I_D = k_m (V_{GS} - V_{TH})^2 ; V_{GS} > V_{TH}$

Conduction parameter $k_m = \frac{1}{2} \frac{W}{L} \cdot \mu_n C_{ox}$; $k_m = \frac{1}{2} k' \frac{W}{L}$; $k' = \mu_n C_{ox}$

Gate capacitance per unit area $C_{ox} = \frac{\epsilon_{ox}}{t_{ox}}$ → Dielectric const of oxide (SiO2)
tox → oxide thickness

P-Channel MOSFET or PMOS:



Changes required:

from		
NMOS		PMOS
V_{GS}	→	V_{SG}
V_{DS}	→	V_{SD}
$V_{TH} (+)$	→	$V_{TP} (-)$
k_m	→	k_p

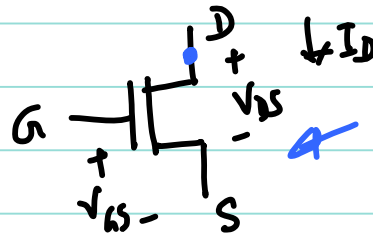
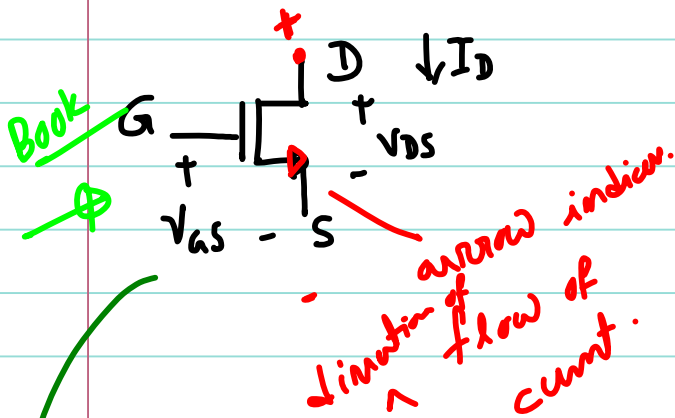
p-ch. mosffet

$k_p = 0.2 \text{ mA/V}^2$; $V_{TP} = -0.5 \text{ V}$, $V_{SG} = 2.08 \text{ V}$

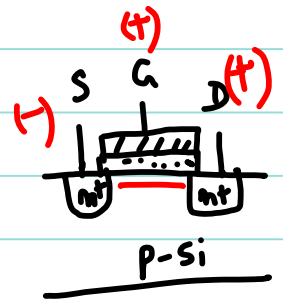
$I_D = k_p (V_{SG} + V_{TP})^2$
 $= 0.2 \times (2.08 - 0.5)^2 \approx 0.5 \text{ mA}$

Circuit Symbol:

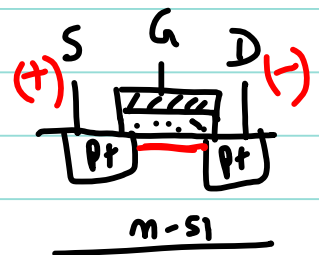
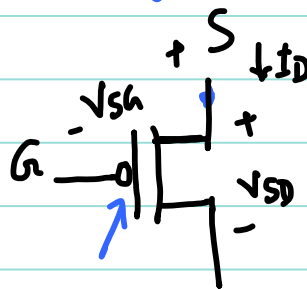
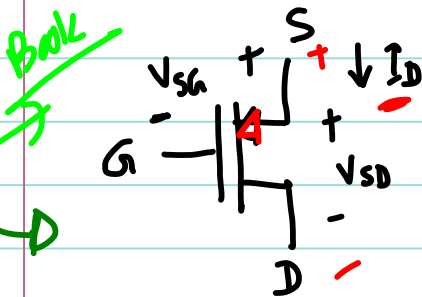
n-channel MOSFET / NMOS:



Symantic device

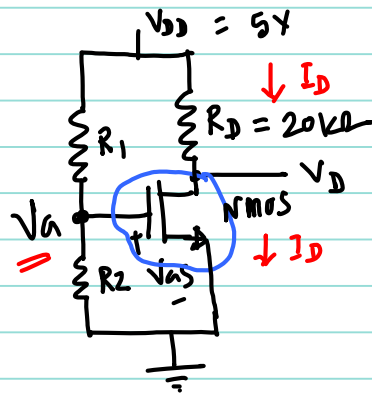


p-channel MOSFET / PMOS:



MOSFET DC Biasing:

(a) Fixed V_{GS} biasing:



Example:

$R_1 = 30k\Omega$, $R_2 = 20k\Omega$
 $V_{THM} = V_{TM} = 1V$
 $k_m = 0.1 \text{ mA/V}^2$

Find I_D ?

$$V_G = V_{GS} = \frac{R_2}{R_1 + R_2} \times V_{DD} = 2V > V_{TM}$$

Transistor is ON.

Assume, MOSFET is in Saturation region.

$$I_D = k_m (V_{GS} - V_{TM})^2 = 0.1 (2 - 1)^2 = 0.1 \text{ mA} \checkmark$$

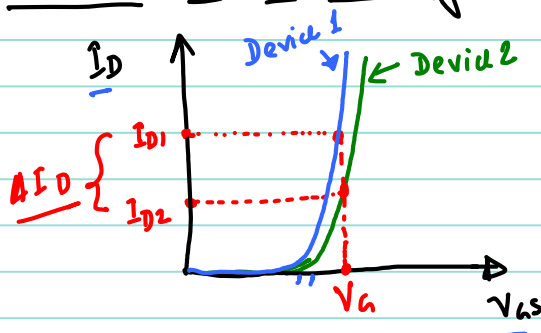
$$V_D = V_{DS} = V_{DD} - I_D R_D = 5 - 0.1 \times 20 = 3V > V_{DS\text{-}sat}$$

$$V_{DS\text{-}sat} = V_{GS} - V_{TM} = 2 - 1 = 1V.$$

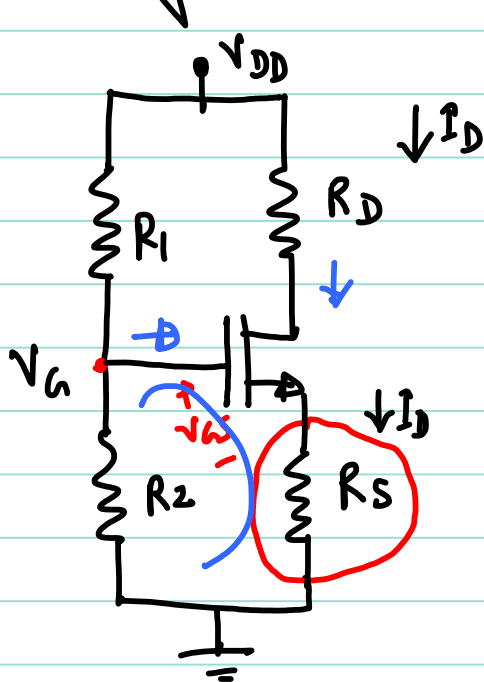
Saturation.

Our assumption is correct.

Comment on the stability:



(b) Biasing with a series resistance at source:



$$V_G = V_{GS} + I_D R_S$$

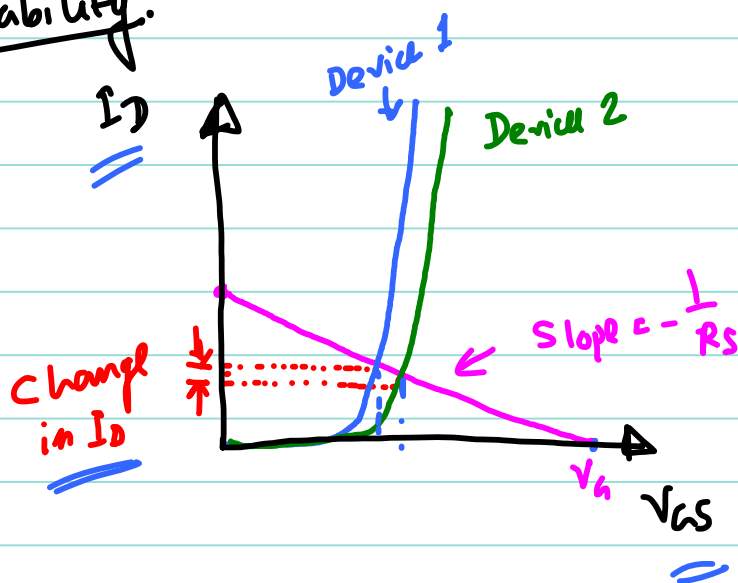
Fixed by R_1, R_2, V_{DD}

Negative Feedback

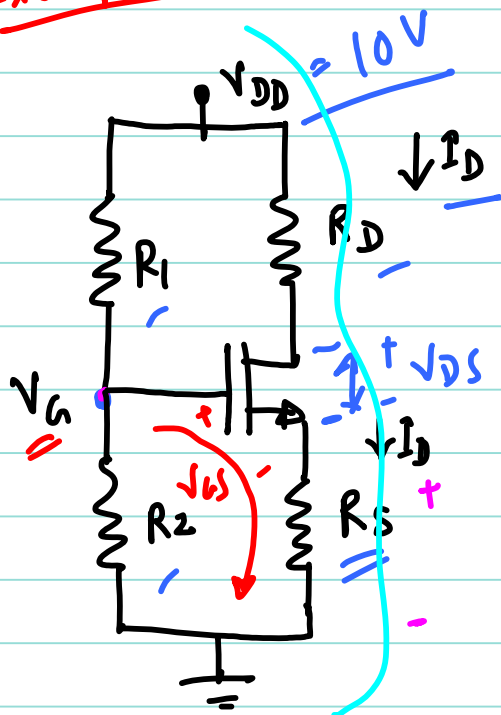
by R_S

for MOSFET, $I_G = 0$
 $I_D = I_S$

Stability:



Example:



$$R_1 = R_2 = 10 \text{ M}\Omega$$

$$R_D = R_S = 6 \text{ k}\Omega$$

$$V_{TH} = 1 \text{ V}, \quad k_m = 0.5 \text{ mA/V}^2$$

Find I_D and V_{DS} .

$$V_G = V_{DD} \times \frac{R_2}{R_1 + R_2} = 5 \text{ V}$$

$$V_G = V_{GS} + I_D R_S$$

$$\underline{V_{GS} = 5 - 6 I_D} \quad ; \quad I_D \text{ is in } \underline{\text{mA}}$$

Assuming saturation condition,

$$I_D = k_m (V_{GS} - V_{TH})^2$$

$$\rightarrow I_D = 0.5 (5 - 6 I_D - 1)^2$$

$$18 I_D^2 - 25 I_D + 4 = 0$$

$$I_D = \underline{0.88 \text{ mA}}, \quad \underline{0.5 \text{ mA}}$$

$$V_{GS} = 5 - 6 I_D$$

$$= 5 - 6 \times 0.5$$

$$V_{GS} = 2 \text{ V.}$$

KVL
Loop:

$$V_{DS} = V_{DD} - I_D (R_D + R_S)$$

$$\underline{V_{DS} = 4 \text{ V}} > V_{DS\text{-sat}}$$

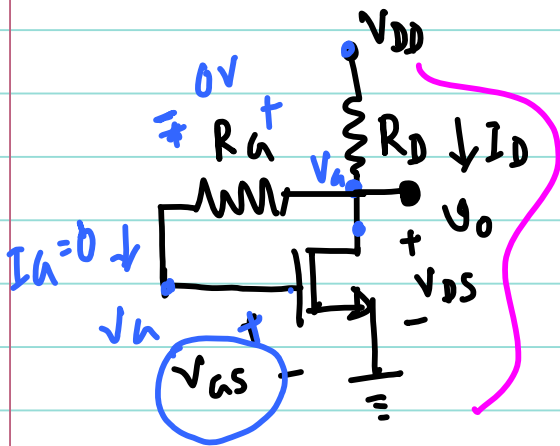
$$V_{DS\text{-sat}} = V_{GS} - V_{TH}$$

$$= 2 - 1$$

$$= \underline{1 \text{ V.}}$$

\hookrightarrow mosFET is in saturation. as assumed.

(C) Biassing using Drain to Gate Feedback Resistor:



$$V_{GS} = V_{DS} ; \quad V_{DS-sat} = V_{GS} - V_{TH}$$

\downarrow
Saturation

$$V_{DS} > V_{DS-sat}$$

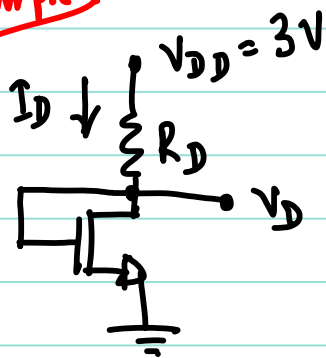
$$V_{DD} = I_D R_D + V_{DS}$$

$$V_{DD} = I_D R_D + V_{GS}$$

\uparrow \downarrow

Negative feedback, Stability

Example:



$$V_{TH} = 0.6V, \quad \mu_n C_{ox} = 200 \mu A/V^2$$

$$L = 0.8 \mu m, \quad W = 4 \mu m$$

$$I_D = 80 \mu A$$

Find V_D .